

Supporting Information

A Supra-monolayer Nanopattern for Organic Nanoparticle Array Deposition

*Sunxi Wang, Daniel J. Sobczynski, Pedram Jahanian, Juxhin Xhahysa, and Guangzhao Mao**

Department of Chemical Engineering and Materials Science, Wayne State University,
5050 Anthony Wayne Drive, Detroit, Michigan 48202, USA

* Corresponding author (Tel. 313 577 3804. E-mail: gzmao@eng.wayne.edu)

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Scheme S1. Side view of various proposed nanostructures of the nanorings used in the fractional surface coverage and contact angle calculations.

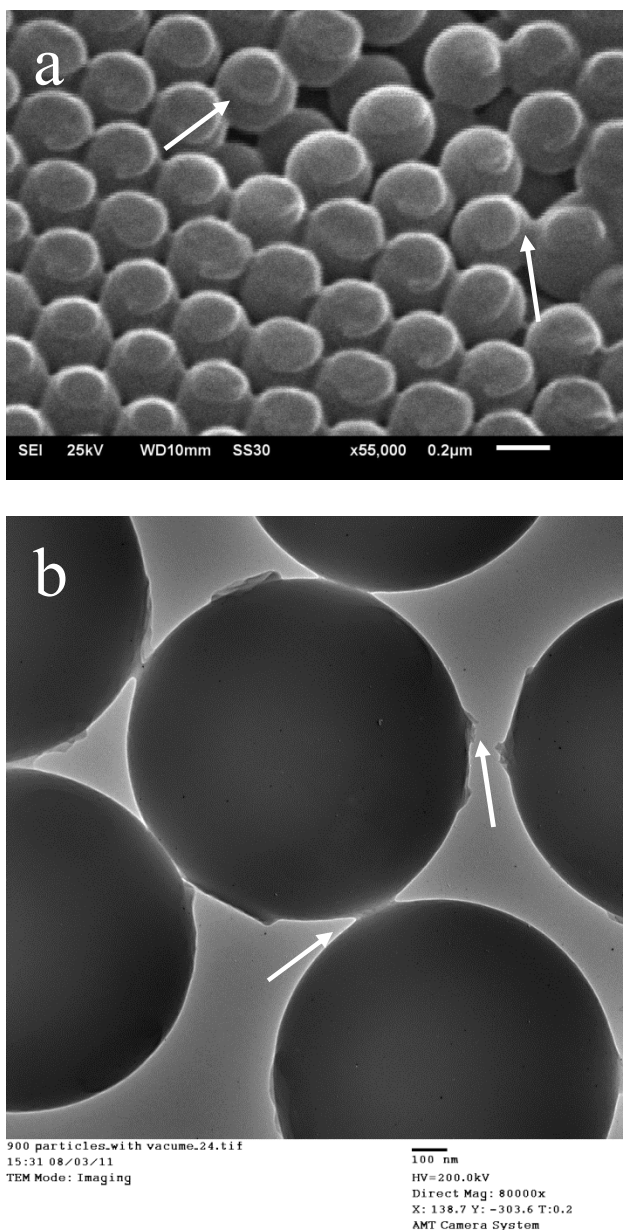


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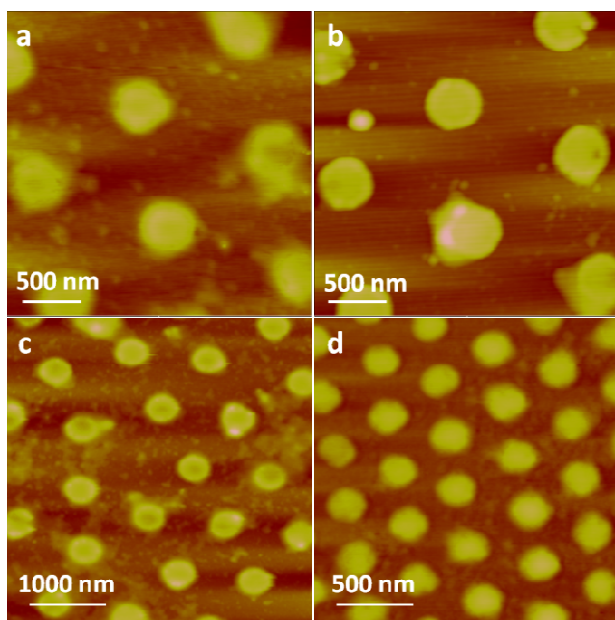


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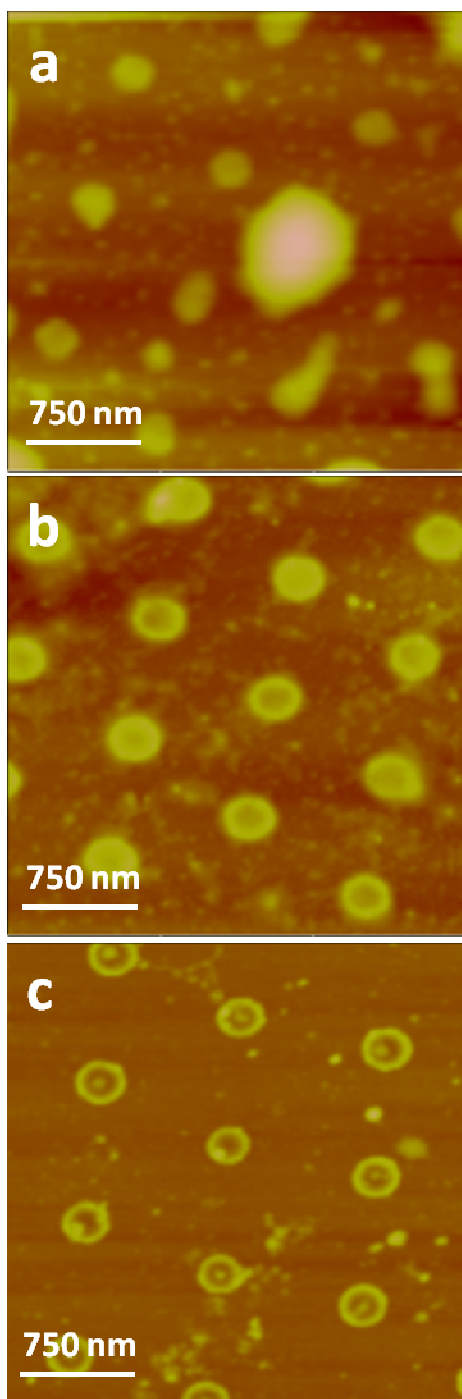
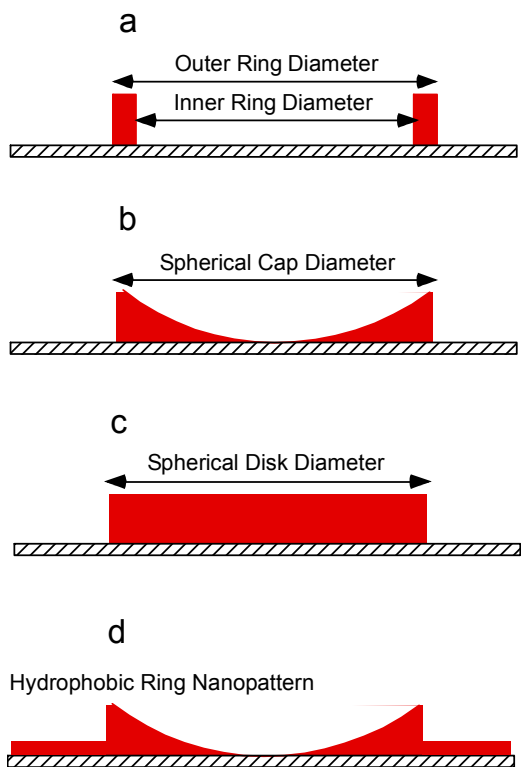


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